

SEARCHED

Class	Sub.	Date	Exmr.
438	787 788 785 240 778 726 393 708	8/16/99 10/19/99	A.M. A.M.

INTERFERENCE SEARCHED

Class	Sub.	Date	Exmr.

SEARCH NOTES (INCLUDING SEARCH STRATEGY)

	Date	Exmr.
Multi chamber + RTO. Remote plasma. plasma treatment	8/16/99	A.M.
Tantalum + Capacitor + plasma + Charge radical or remote	4/27/01	A.M.
IEEE: Tantalum + Capacitor + meal. EAST: Remote + plasma Capacitor + tantalum	4/17/02 	A.M.

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